

Abstract**Separating apparatus for polysilicon**

5 The invention provides a separating apparatus for polysilicon having at least one screen plate (1), comprising a feed region (2) for polysilicon, a profiled region (3) having peaks (32) and valleys (31), a region (4) having screen apertures (41) which adjoins the profiled region (3), and a takeoff region (5), wherein the screen apertures (41) widen in the direction of the takeoff region (5), and a separating plate (7) arranged below the screen apertures which is horizontally and vertically displaceable.

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Drawing relating to abstract: Fig. 1